

5. The method for manufacturing a glass substrate for an information recording medium according to any one of claims 1 to 3,

wherein in the step of removing the polished glass substrate from the surface plate, the polished glass substrate is removed from the surface plate in a state in which the polishing pad still contains the liquid polishing agent.

6. The method for manufacturing a glass substrate for an information recording medium according to claim 5,

wherein in the step of removing the polished glass substrate from the surface plate by adding a new slurry, the liquid polishing agent has a concentration that is 1.5-fold or more when compared with a concentration of the liquid polishing agent in the step of polishing the surface of the glass substrate using the polishing device.

7. A method for manufacturing an information recording medium, characterized in that at least a magnetic film is formed on a surface of a glass substrate for an information recording medium obtained in accordance with the method for manufacturing a glass substrate for an information recording medium as recited in any one of claims 1 to 6.

8. ~~A polishing pad mounted on a surface plate of a polishing device and used for a polishing process, characterized in that~~

~~the polishing pad has a plurality of foam cells and a plurality of communication holes that allow adjacent foam cells of the foam cells to communicate with each other, and~~

~~in a section of the polishing pad taken in a direction normal to the surface plate, the communication holes having a cross-sectional area of 0.01 mm² or more are present at a density of 30 or more communication holes per 25 mm² of the section.~~